

# *Fundamentals of Solid State Physics*

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## Optical Properties

Xing Sheng 盛兴



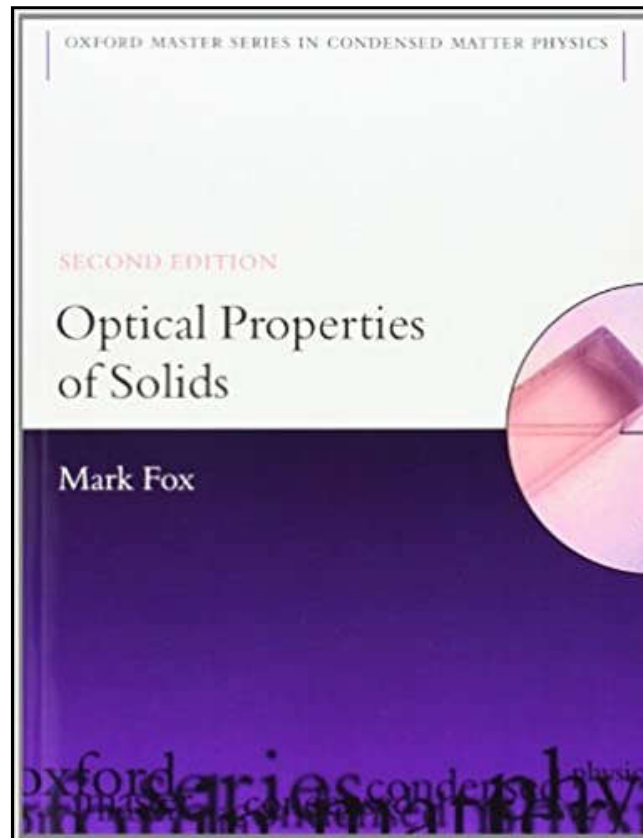
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# Further Reading

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- Fox, Chapter 1, 2, 7



# Optical Properties of Materials



**Metal**



**SiO<sub>2</sub>**



**Silicon**

- **Crystal Structures**
  - polycrystalline, amorphous, single crystalline
- **Electronics**
  - conductor, insulator, semiconductor
- **Optics (in the visible range)**
  - reflective, transparent, absorbing

# *Fundamentals of Solid State Physics*

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## Optical Processes

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# Optical Processes

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- **Review: Maxwell's Equations**
- **Reflection, Transmission, Absorption, ...**
- **Optical propagation in multi-layers**
  - **Transfer Matrix Method**

# Electrodynamics

## ■ Maxwell's Equations

$$\nabla \cdot \mathbf{D} = \rho_V$$

$$\nabla \cdot \mathbf{B} = 0$$

$$\nabla \times \mathbf{E} = -\frac{\partial \mathbf{B}}{\partial t}$$

$$\nabla \times \mathbf{H} = \frac{\partial \mathbf{D}}{\partial t} + \mathbf{J}$$

$$\oint_s \mathbf{D} \cdot d\mathbf{A} = \int_v \rho \cdot dV$$

$$\oint_s \mathbf{B} \cdot d\mathbf{A} = 0$$

$$\oint_l \mathbf{E} \cdot d\mathbf{l} = -\int_s \frac{\partial \mathbf{B}}{\partial t} \cdot d\mathbf{A}$$

$$\oint_l \mathbf{H} \cdot d\mathbf{l} = \int_s \mathbf{J} \cdot d\mathbf{A} + \int_s \frac{\partial \mathbf{D}}{\partial t} \cdot d\mathbf{A}$$

# Electrodynamics

## Maxwell's Equations

$$\begin{aligned}\nabla \cdot \mathbf{D} &= \rho_V \\ \nabla \cdot \mathbf{B} &= 0 \\ \nabla \times \mathbf{E} &= -\frac{\partial \mathbf{B}}{\partial t} \\ \nabla \times \mathbf{H} &= \frac{\partial \mathbf{D}}{\partial t} + \mathbf{J}\end{aligned}$$

## Constitutive Relations

### 本构关系

$$\begin{aligned}\mathbf{B} &= \mu_0 \mu_r \mathbf{H} \\ \mathbf{D} &= \varepsilon_0 \varepsilon_r \mathbf{E}\end{aligned}$$

$\varepsilon_0 \varepsilon_r$  - Permittivity (dielectric constant)

$\varepsilon_r = 1$  for vacuum

$\varepsilon_0 = 8.85 \cdot 10^{-12}$  F/m

$\mu_0 \mu_r$  - Permeability

$\mu_r = 1$  for vacuum

$\mu_0 = 4\pi \cdot 10^{-7}$  H/m

# Electrodynamics

## Maxwell's Equations

$$\begin{aligned}\nabla \cdot \mathbf{D} &= \rho_V \\ \nabla \cdot \mathbf{B} &= 0 \\ \nabla \times \mathbf{E} &= -\frac{\partial \mathbf{B}}{\partial t} \\ \nabla \times \mathbf{H} &= \frac{\partial \mathbf{D}}{\partial t} + \mathbf{J}\end{aligned}$$

## Constitutive Relations

### 本构关系

$$\begin{aligned}\mathbf{B} &= \mu_0 \mu_r \mathbf{H} \\ \mathbf{D} &= \varepsilon_0 \varepsilon_r \mathbf{E}\end{aligned}$$

For most non-magnetic materials (no magnetic field),  
 $\mu_r = 1$

Optical properties of materials  
is determined by  $\varepsilon_r$



# Electrodynamics

## ■ In vacuum

□  $\rho_V = 0, \mathbf{J} = 0$

□  $\mu_r = 1, \epsilon_r = 1$

$$\begin{aligned}\nabla \cdot \mathbf{D} &= \rho_V \\ \nabla \cdot \mathbf{B} &= 0 \\ \nabla \times \mathbf{E} &= -\frac{\partial \mathbf{B}}{\partial t} \\ \nabla \times \mathbf{H} &= \frac{\partial \mathbf{D}}{\partial t} + \mathbf{J}\end{aligned}$$

$$\nabla^2 \mathbf{E} = \mu_0 \epsilon_0 \frac{\partial^2 \mathbf{E}}{\partial t^2}$$



$$\mathbf{E}(x, t) = \mathbf{E}_0 e^{i(kx - \omega t)}$$

**Plane Wave**

$$k = \frac{2\pi}{\lambda}$$

$$\omega = \frac{2\pi}{T}$$

**wavevector**

**angular frequency**

# Electrodynamics

## ■ In vacuum

- $\rho_V = 0, \mathbf{J} = 0$
- $\mu_r = 1, \epsilon_r = 1$

$$\begin{aligned}\nabla \cdot \mathbf{D} &= \rho_V \\ \nabla \cdot \mathbf{B} &= 0 \\ \nabla \times \mathbf{E} &= -\frac{\partial \mathbf{B}}{\partial t} \\ \nabla \times \mathbf{H} &= \frac{\partial \mathbf{D}}{\partial t} + \mathbf{J}\end{aligned}$$

$$\nabla^2 \mathbf{E} = \mu_0 \epsilon_0 \frac{\partial^2 \mathbf{E}}{\partial t^2}$$



$$\mathbf{E}(x, t) = \mathbf{E}_0 e^{i(kx - \omega t)}$$

**Plane Wave**

$$c = \frac{\omega}{k} = \frac{1}{\sqrt{\mu_0 \epsilon_0}} = 3 \times 10^8 \text{ m/s}$$

**light speed in vacuum**

# Electrodynamics

- In a dielectric medium

- $\rho_V = 0, \mathbf{J} = 0$

- $\mu_r = 1, \epsilon_r \neq 1$

$$\begin{aligned}\nabla \cdot \mathbf{D} &= \rho_V \\ \nabla \cdot \mathbf{B} &= 0 \\ \nabla \times \mathbf{E} &= -\frac{\partial \mathbf{B}}{\partial t} \\ \nabla \times \mathbf{H} &= \frac{\partial \mathbf{D}}{\partial t} + \mathbf{J}\end{aligned}$$



$$\nabla^2 \mathbf{E} = \mu_0 \epsilon_0 \epsilon_r \frac{\partial^2 \mathbf{E}}{\partial t^2}$$

$$\mathbf{E}(x, t) = \mathbf{E}_0 e^{i(kx - \omega t)}$$

Plane Wave

$$v = \frac{\omega}{k} = \frac{c}{\sqrt{\epsilon_r}} = \frac{c}{n}$$

$$\epsilon_r = n^2$$

light speed in a material

$n$  - refractive index (折射率)

# Electrodynamics

- In a dielectric medium

- $\rho_V = 0, \mathbf{J} = 0$

- $\mu_r = 1, \epsilon_r \neq 1$

$$\mathbf{E}(x, t) = \mathbf{E}_0 e^{i(kx - \omega t)}$$

**Plane Wave**

$$k = \frac{2\pi}{\lambda'} = \frac{2\pi}{\lambda_0} n$$

$\lambda'$  - wavelength in the medium

$\lambda_0$  - wavelength in vacuum

Frequency  $\omega$  does not change

# Complex Form of $\varepsilon_r$ and $n$

$$\tilde{\varepsilon}_r = \tilde{n}^2$$

$$\tilde{\varepsilon}_r = \varepsilon_1 + i\varepsilon_2$$

$$\tilde{n} = n + i\kappa$$

$$\rightarrow \begin{cases} \varepsilon_1 = n^2 - \kappa^2 \\ \varepsilon_2 = 2n\kappa \end{cases}$$

$\varepsilon_r$  and  $n$  depend on optical frequency / wavelength

# Complex Form of $\varepsilon_r$ and $n$

$$\begin{cases} n = \frac{1}{\sqrt{2}} \left( \varepsilon_1 + \sqrt{\varepsilon_1^2 + \varepsilon_2^2} \right)^{1/2} \\ \kappa = \frac{1}{\sqrt{2}} \left( -\varepsilon_1 + \sqrt{\varepsilon_1^2 + \varepsilon_2^2} \right)^{1/2} \end{cases}$$

when  $\varepsilon_1 \gg \varepsilon_2$  (or  $n \gg \kappa$ ), weakly absorbing

$$\rightarrow \begin{cases} n \approx \sqrt{\varepsilon_1} \\ \kappa \approx \frac{\varepsilon_2}{2n} \end{cases}$$

# Reflection 反射

## Incident wave

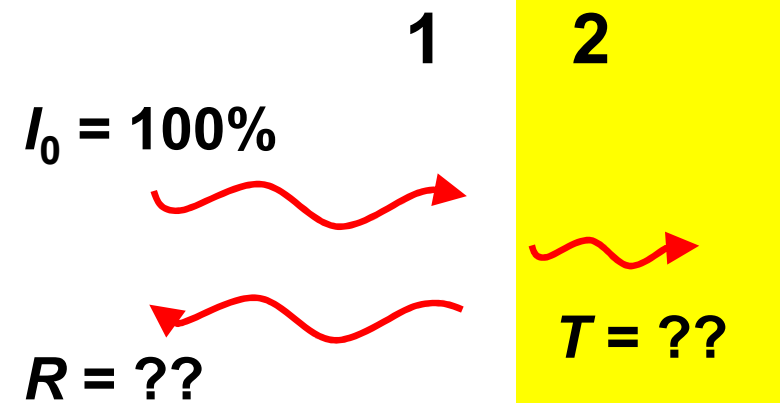
$$\mathbf{E}(x, t) = \mathbf{E}_0 e^{i(kx - \omega t)}$$

## Intensity

$$I \propto |\mathbf{E}|^2$$

## Reflective wave

$$\mathbf{E}_R(x, t) = \mathbf{E}_R e^{i(-kx - \omega t)}$$



## Reflectivity 反射率

based on boundary conditions  
of Maxwell's Equations

$$R = \left| \frac{\mathbf{E}_R}{\mathbf{E}_0} \right|^2 = \left| \frac{\tilde{n}_2 - \tilde{n}_1}{\tilde{n}_2 + \tilde{n}_1} \right|^2$$

If medium 1 is air ( $\tilde{n}_1 = 1$ )

$$R = \left| \frac{\tilde{n}_2 - 1}{\tilde{n}_2 + 1} \right|^2 = \frac{(n - 1)^2 + \kappa^2}{(n + 1)^2 + \kappa^2}$$

for normal incidence ( $\theta = 0$ )

## Transmission 透射率

$$T = 1 - R$$

# Absorption 吸收

Incident wave

$$\mathbf{E}(x, t) = \mathbf{E}_0 e^{i(kx - \omega t)}$$

Intensity

$$I \propto |\mathbf{E}|^2$$

After traveling a distance  $L$

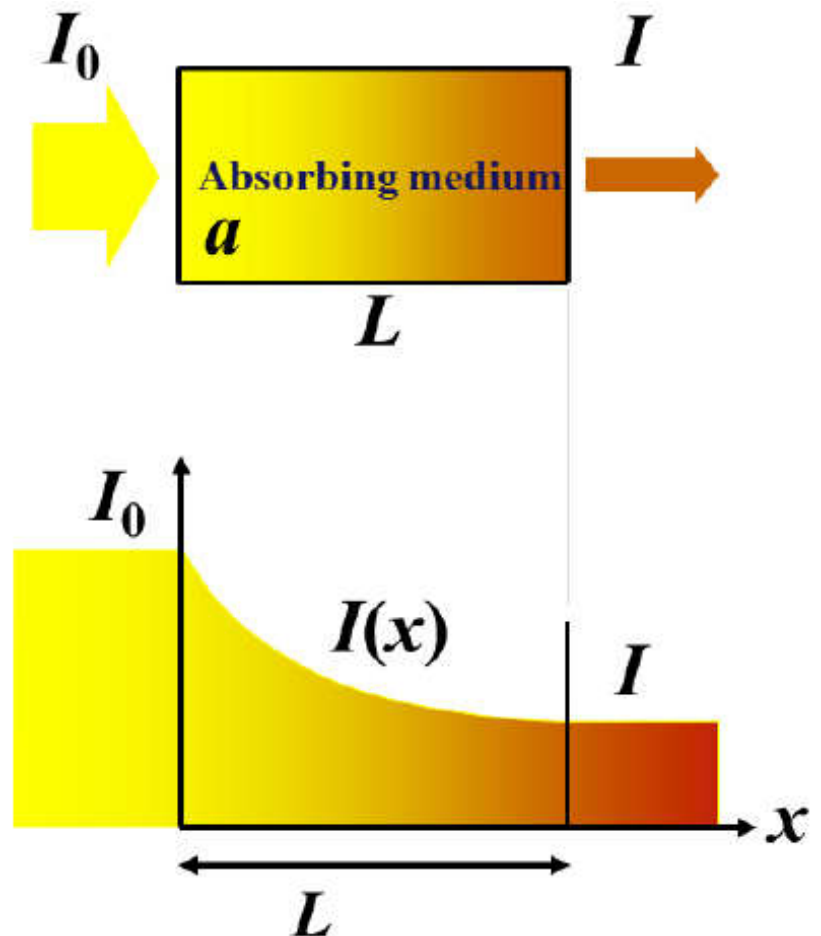
$$\begin{aligned} \mathbf{E}_T(x, t) &= \mathbf{E}_0 e^{i(kx - \omega t)} e^{ikL} \\ &= \mathbf{E}_0 e^{i(kx - \omega t)} e^{i2\pi\tilde{n}/\lambda^*L} \\ &= \mathbf{E}_0 e^{i(kx - \omega t)} e^{i2\pi n/\lambda^*L} e^{-2\pi\kappa/\lambda^*L} \end{aligned}$$

Lambert Beer's Law

$$I = I_0 e^{-\alpha L}$$

$$\alpha = \frac{4\pi\kappa}{\lambda}$$

absorption coefficient (unit: /m)



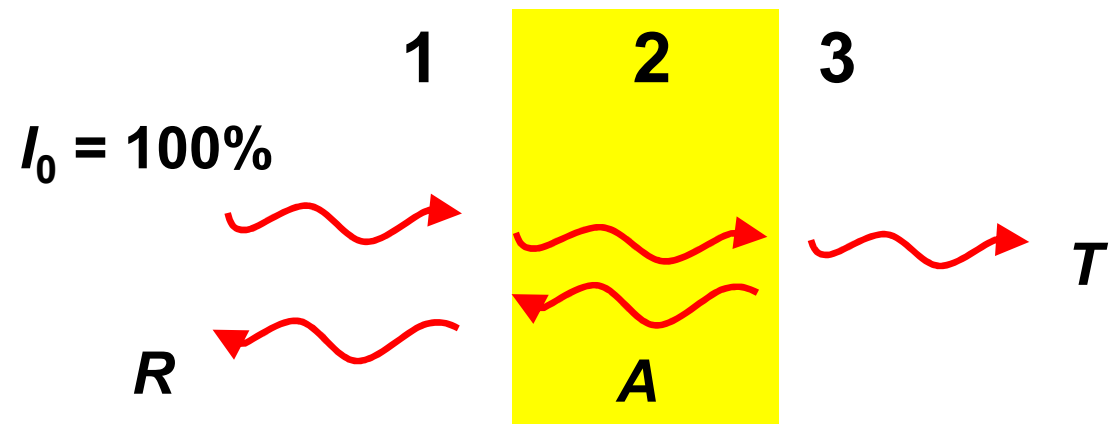


# Transmission 透射

Reflection  $R$  反射

Absorption  $A$  吸收

Transmission  $T$  透射



$$R + A + T = 1$$

# Example: Silicon

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- At  $\lambda = 600$  nm, for Si,  $\tilde{n} = 3.94 + i*0.025$ , calculate
  - Reflection  $R$  at the air/Si interface
  - Absorption coefficient  $\alpha$  at 600 nm
  - Absorption by a Si film with thickness  $L = 0.01$  mm

# Example: Silicon

- At  $\lambda = 600$  nm, for Si,  $\tilde{n} = 3.94 + i*0.025$ , calculate
  - Reflection  $R$  at the air/Si interface
  - Absorption coefficient  $\alpha$  at 600 nm
  - Absorption by a Si film with thickness  $L = 0.01$  mm

$$R = \frac{(n-1)^2 + \kappa^2}{(n+1)^2 + \kappa^2} = 35.4\%$$

$$\alpha = \frac{4\pi\kappa}{\lambda} = 5.24 * 10^5 / \text{m}$$

$$A = 1 - e^{-\alpha L} = 99.5\%$$

# Example: Silicon

- Silicon is a very good absorber at  $\lambda = 600$  nm
- It can be used to make solar cells and cameras
- Surface reflection is very strong
- It needs an anti-reflective coating ARC (减反膜)

$$R = \frac{(n-1)^2 + \kappa^2}{(n+1)^2 + \kappa^2} = 35.4\%$$

$$\alpha = \frac{4\pi\kappa}{\lambda} = 5.24 * 10^5 / \text{m}$$

$$A = 1 - e^{-\alpha L} = 99.5\%$$



bare  
Si  
wafer



Si  
solar cell  
with ARC

# Example: Silver

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- At  $\lambda = 600$  nm, for Ag,  $\tilde{n} = 0.12 + i*3.66$ , calculate
  - Reflection  $R$  at the air/Ag interface
  - Absorption coefficient  $\alpha$  at 600 nm
  - Absorption by a Ag film with thickness  $L = 100$  nm

# Example: Silver

- At  $\lambda = 600$  nm, for Ag,  $\tilde{n} = 0.12 + i*3.66$ , calculate
  - Reflection  $R$  at the air/Ag interface
  - Absorption coefficient  $\alpha$  at 600 nm
  - Absorption by a Ag film with thickness  $L = 100$  nm

$$R = \frac{(n-1)^2 + \kappa^2}{(n+1)^2 + \kappa^2} = 96.7\%$$

$$\alpha = \frac{4\pi\kappa}{\lambda} = 7.67 * 10^7 / \text{m}$$

$$A = 1 - e^{-\alpha L} = 99.95\%$$

# Example: Silver

- Ag is a very good mirror at visible wavelengths
- Light can only propagate in Ag at a very small depth

$$R = \frac{(n-1)^2 + \kappa^2}{(n+1)^2 + \kappa^2} = 96.7\%$$

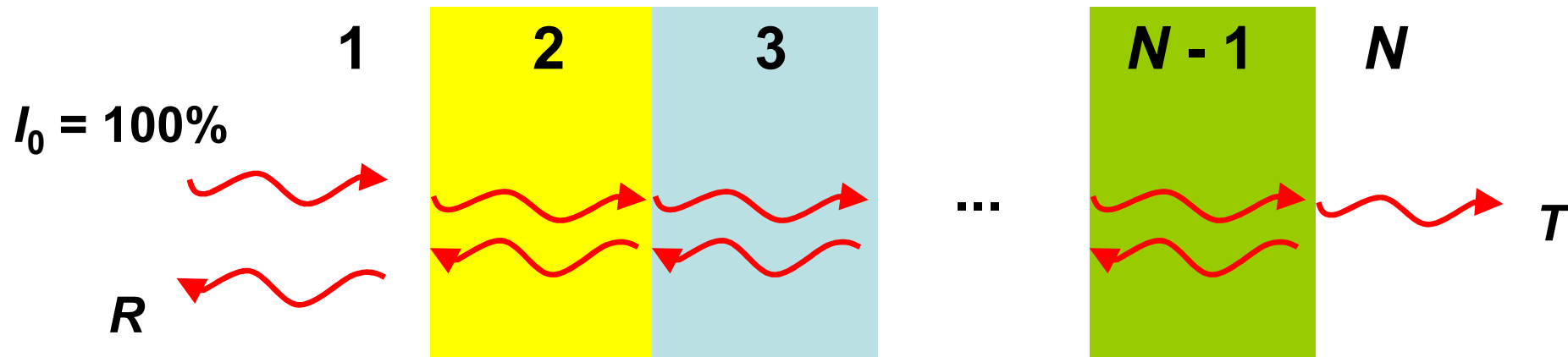
$$\alpha = \frac{4\pi\kappa}{\lambda} = 7.67 * 10^7 / \text{m}$$

$$A = 1 - e^{-\alpha L} = 99.95\%$$



**mirror reflection**

# Multilayer Optical Structures



Solution based on the boundary conditions of Maxwell's Equations

calculated by *Transfer Matrix Method*  
Lecture Note 5.2



# Example: Anti-Reflective Coating (ARC)

At  $\lambda = 600$  nm, no ARC

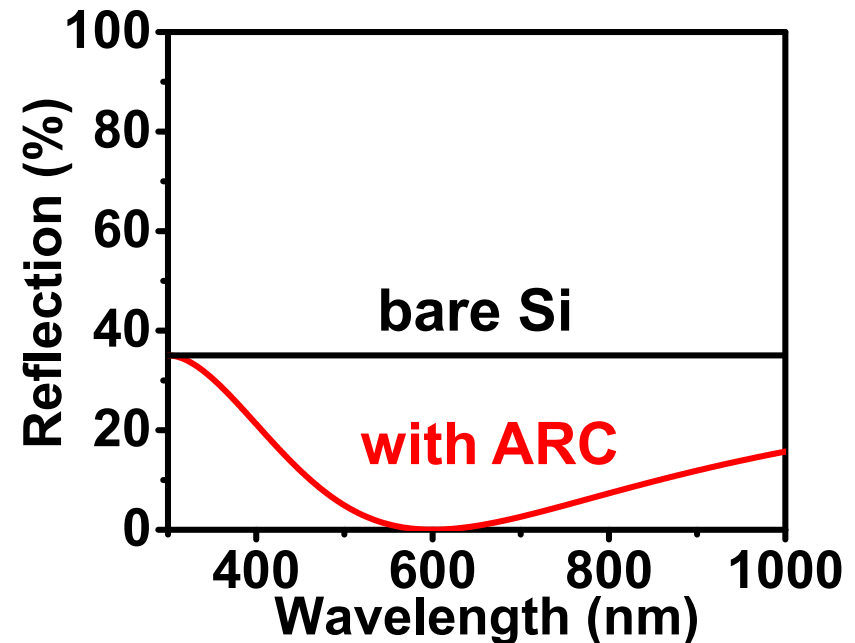
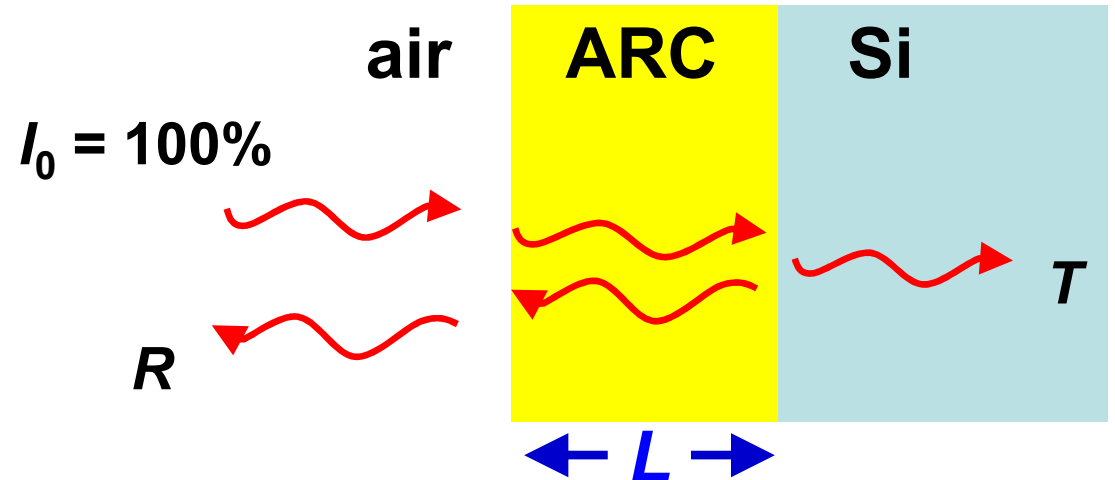
$$R(\text{air/Si}) = 35.4\%$$

Design an ARC

$$n = \sqrt{n(\text{air}) * n(\text{Si})} = 1.98$$

$$L = \frac{\lambda}{4n} = 75 \text{ nm}$$

$$R(\lambda = 600 \text{ nm}) = 0$$



Homework 9.1

# Example: ARC for Si

At  $\lambda = 600$  nm, no ARC

$$R(\text{air/Si}) = 35.4\%$$

Design an ARC

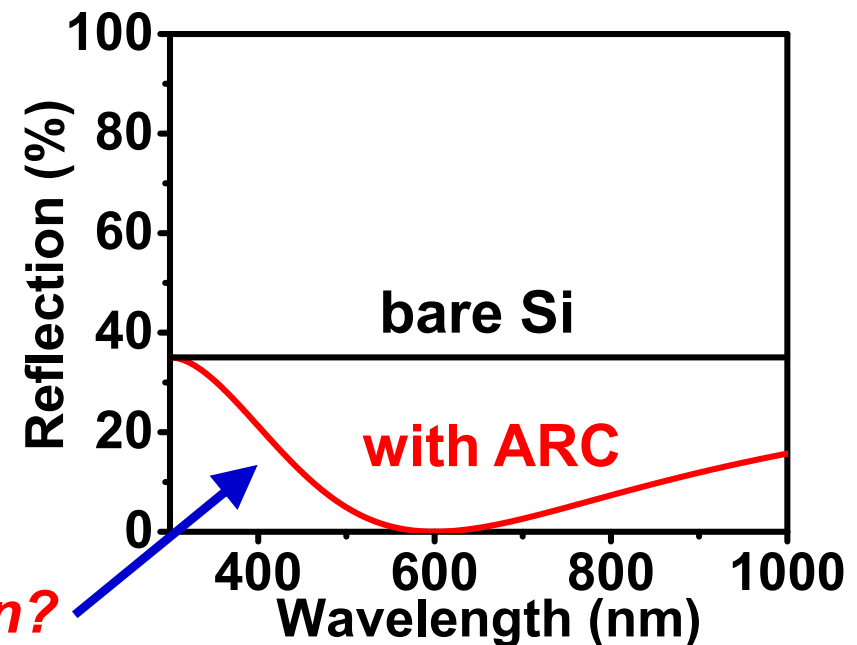
$$n = \sqrt{n(\text{air}) * n(\text{Si})} = 1.98$$

$$L = \frac{\lambda}{4n} = 75 \text{ nm}$$

$$R(\lambda = 600 \text{ nm}) = 0$$



A Si solar cell  
with ARC  
looks blue



**Q: How to further reduce the reflection?**

# Example: ARC for Glass

For glass

$$n = 1.45$$

At  $\lambda = 600$  nm, no ARC

$$R(\text{air/glass}) = 3.4\%$$



**without ARC**

**Design an ARC**

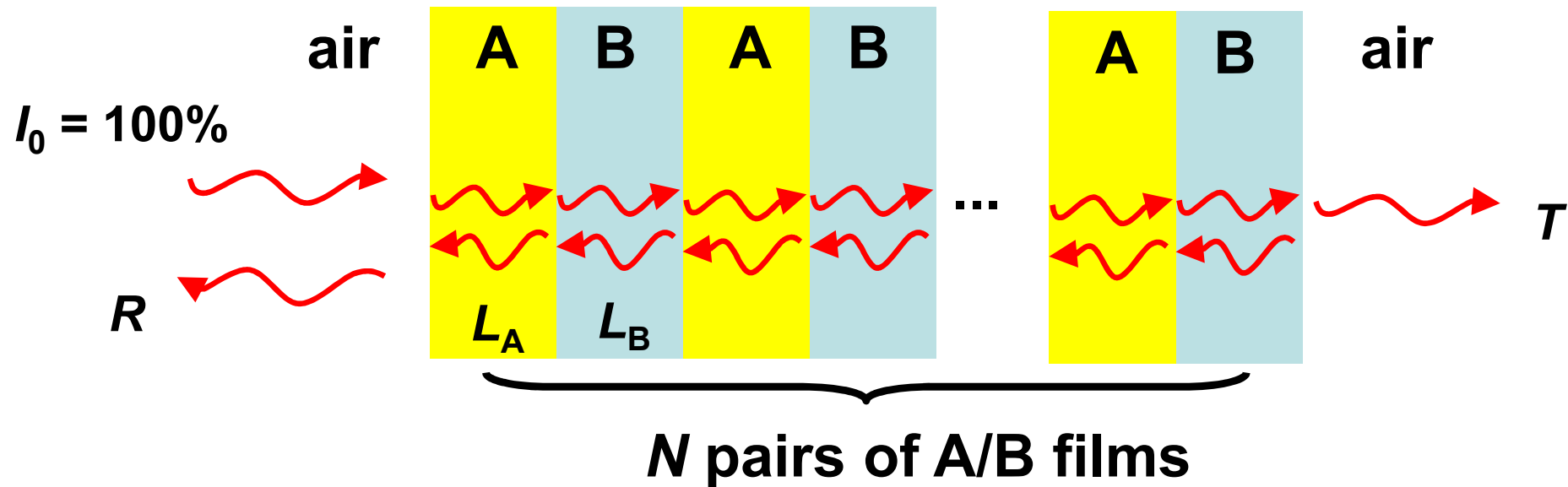
$$n = \sqrt{n(\text{air}) * n(\text{glass})} = 1.2$$

$$\text{thickness} = \frac{\lambda}{4n} = 125 \text{ nm}$$



**with ARC**

# Example: Bragg Reflector



If we choose

$$L_A = \frac{\lambda}{4n_A}$$

$$L_B = \frac{\lambda}{4n_B}$$

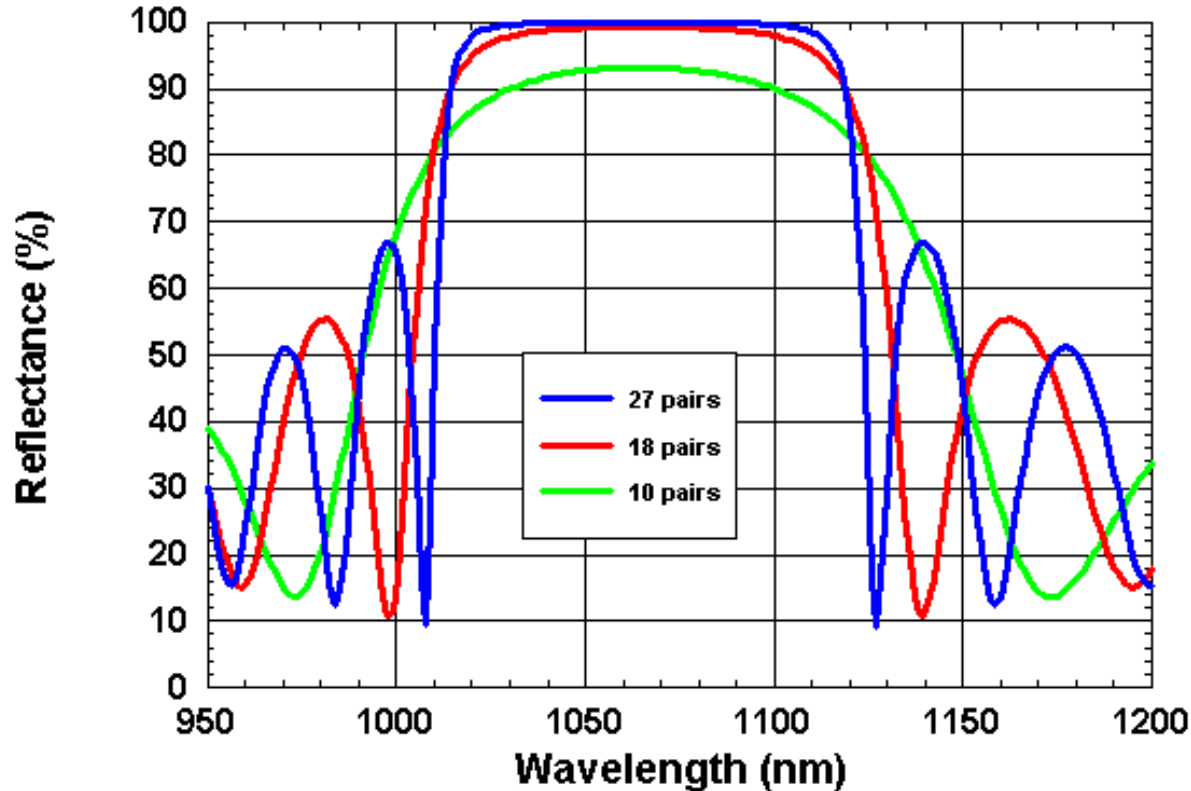
Project 3

$$R = \left( \frac{n_A^{2N} - n_B^{2N}}{n_A^{2N} + n_B^{2N}} \right)^2$$

If  $n_A \neq n_B$ , when  $N \rightarrow +\infty$

$R \rightarrow 100\%$

# Example: Bragg Reflector



**A perfect mirror  
(Bragg mirror)  
(better than silver)**

**1D photonic crystal  
(光子晶体)**

**Project 2**

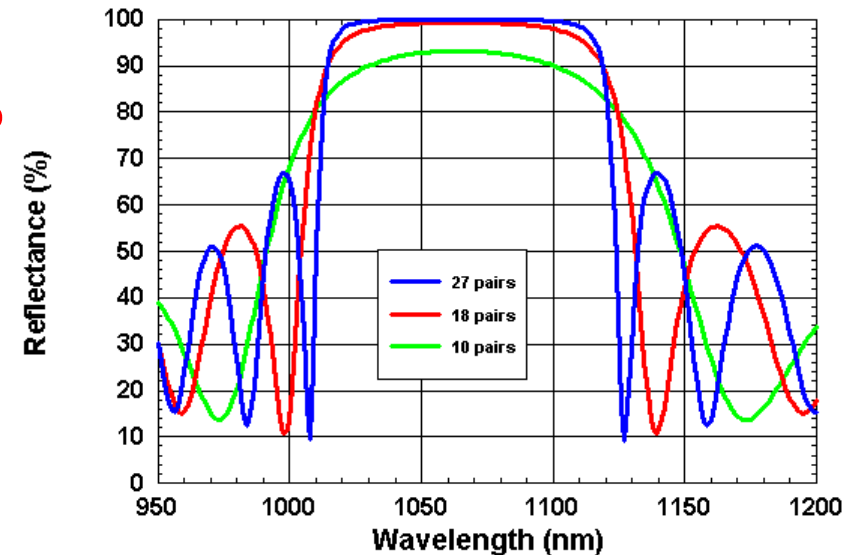
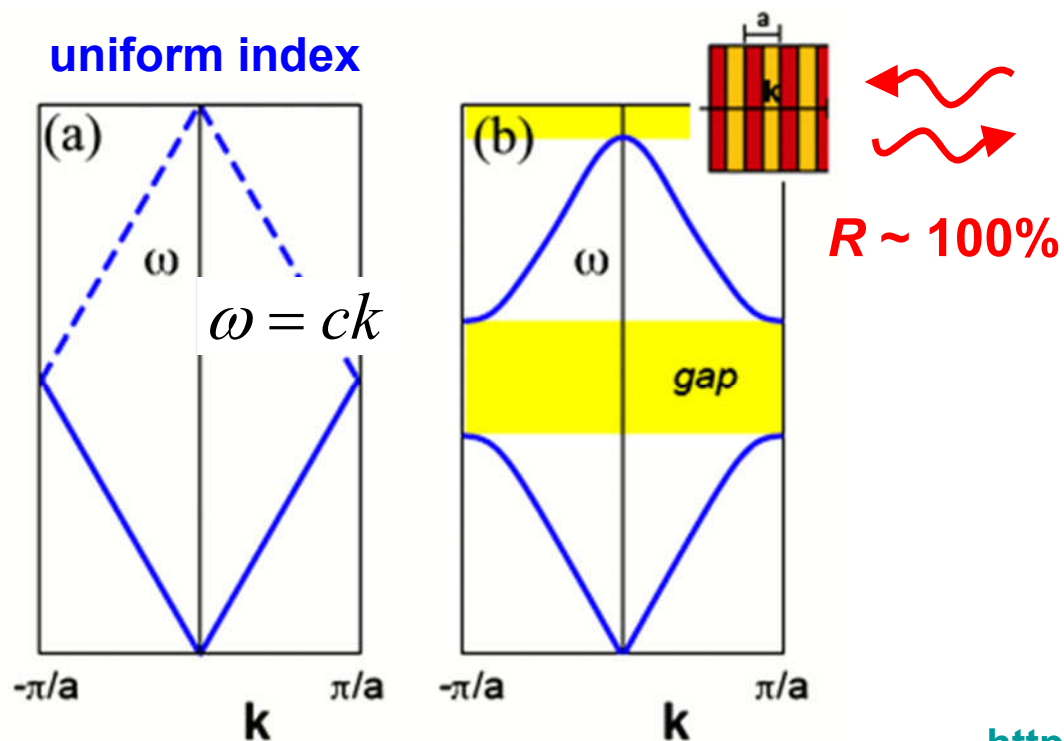
$$R = \left( \frac{n_A^{2N} - n_B^{2N}}{n_A^{2N} + n_B^{2N}} \right)^2$$

If  $n_A \neq n_B$ , when  $N \rightarrow +\infty$

$R \rightarrow 100\%$

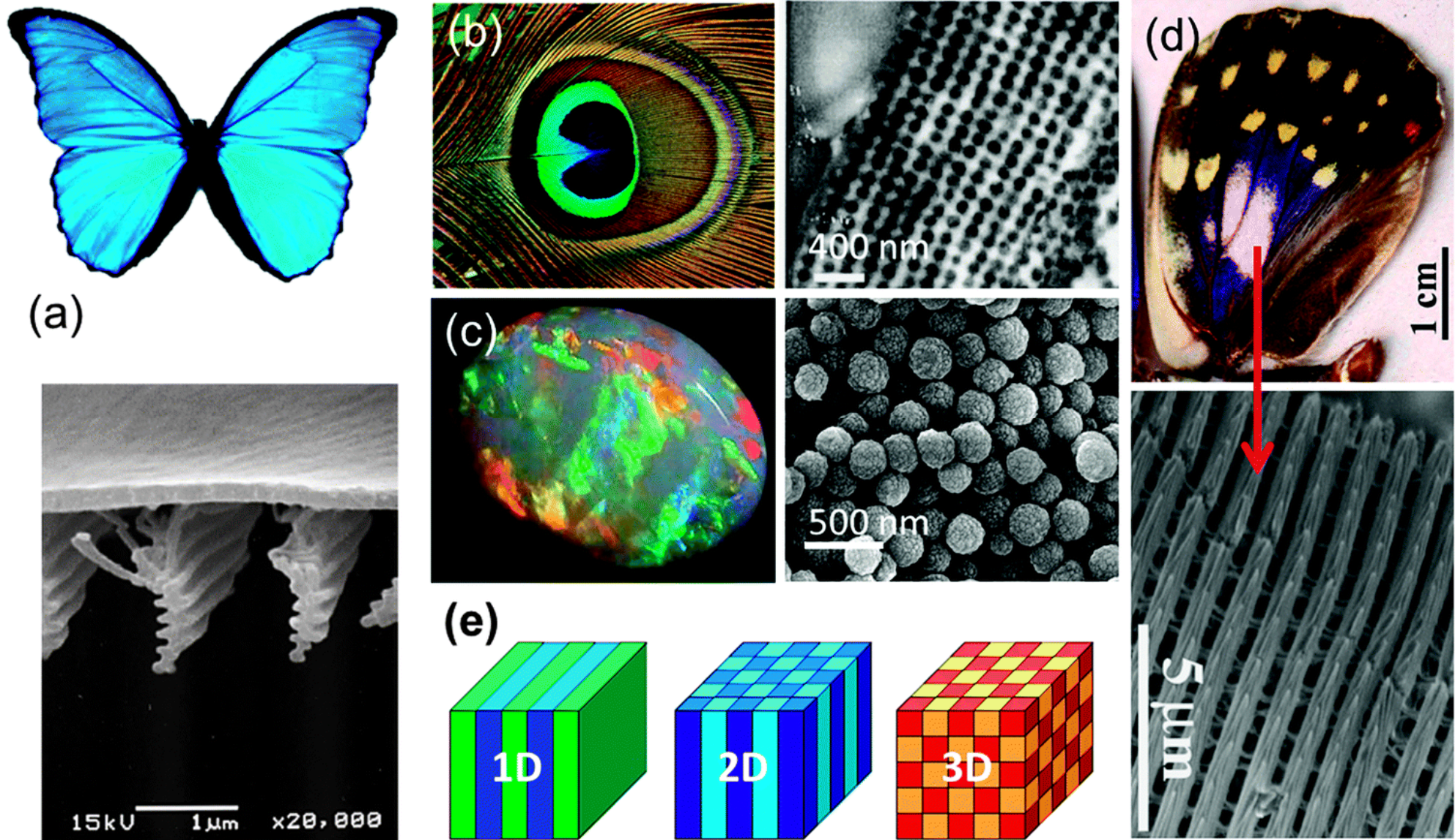
# Photonic Crystals (光子晶体)

- Periodically structured optical media
  - Forming photonic band gaps
  - no light can pass through (~100% reflection)
  - color created by structure, not material absorption





# Photonic Crystals in Nature



***Thank you for your attention***